



NOTES

1. MATERIAL: UVFS
2. CLEAR APERTURE: 22 mm
3. CENTER APERTURE: 669 nm
4. FWHM: 51 nm
5. TRANSMITTED WAVEFRONT: $\lambda @ 633 \text{ nm}$
6. SURFACE QUALITY: 60/40(S/D)
7. COATING: BANDPASS FILTER, 0° AOI
 Tabs $\geq 95\% @ 670 \text{ nm}$;
 ODabs ≥ 5 , ODavg $\geq 6 @ 300 \text{ nm} - 635 \text{ nm}$;
 ODabs ≥ 3 , ODavg $\geq 4 @ 705 \text{ nm} - 1000 \text{ nm}$;

DRAWING PROJECTION			LBTEK			
	NAME	DATE	ET670/50m			
DRAWN	LZHOU	JUL./2nd/24	PREMIUM BANDPASS FILTER $\phi 25 \text{ mm}$, CWL=669 nm, FWHM=51 nm			
APPROVAL	WCHENG	JUL./2nd/24	MATERIAL	WEIGHT	SCALE	REV
FOR INFORMATION ONLY NOT FOR MANUFACTURING PURPOSES			UVFS	1.5 g	2:1	A